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INVESTIGATION OF POTENTIAL INDUCED DEGRADATION ON THE REAR SIDE OF BIFACIAL PERC+ SOLAR CELLS

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INTRODUCTION AND MOTIVATION

- PERC+ cell concept [1] successfully introduced to mass production
- bifacial gain facilitates reduced LCOE
- absence of full cover rear side metallization: potential of solar cells no longer shielded versus grounded frame or glass on rear side [2]

Is rear side of bifacial PERC cells prone to PID ?

EXPERIMENTAL

Samples and testing conditions

- three types industrially produced PERC+ cells in test
- batches A, B, C, two cells per batch
- 20 cm x 20 cm one cell modules built from each cell type
- material stack: 3 mm glass / EVA / cell / EVA / 3 mm glass



- module stressed under U_{PID} = +1000 V applied to brass plate, cell at ground level
- test duration = 24 h to 96 h, cell temperature 60°C
- dark IV curve measured in 5 min interval during degradation using source meter
- time, temperature voltage according to SEMI PV75-1016

PID sensitivity tested for front and rear side

OVERVIEW: DEGRADATION IN CELL PARAMETERS

Illuminated I-V characteristics - on LED solar simulator (STC)



main impact on FF for A and C typical for PID-s [3]

all cells in test are prone to degradation from the rear side, so called PID-p causes passivation failure

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local PID test on PIDcon [4]



stress at 1000V bias voltage, rear side

photograph of cell with rear side up: locally PID stressed at highlighted area

Hypothesis:

positive ions enrich in AIO, layer, reducing field effect passivation [5]

up

structural defects or stacking faults in Si or AlO, facilitates PID-p [6]

PID-p BAND DIAGRAM MODEL



- rear side passivation by field effect of negative charges in AlO_x layer
- initial state: electrons repelled from fixed negative charges in AlO,
- PID-p state: positive ions, e.g. Sodium, overcompensate AIO_x layer [6]

break down of field effect passivation can explain PID-p

SUMMARY

- 1. PERC+ cells in glass/glass module suffer from PID at rear side
- 2. PID-p type reduced open circuit voltage and current, rather than fill factor
- 3. lateral inhomogeneous degradation: structural defects facilitate PID-p
- presumably PID-p relates to local breakdown of field effect passivation of AlO_x layer caused by in-diffusion of positive ions

REFERENCES

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